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PTO/SB/08B (08-00)  
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|   |   |    |   | Application Number       | Not Yet Assigned |
|   |   |    |   | Filing Date              |                  |
|   |   |    |   | First Named Inventor     | Masahiko Ando    |
|   |   |    |   | Group Art Unit           | N/A              |
|   |   |    |   | Examiner Name            | Not Yet Assigned |
| Sheet   | 1 | of | 1 | Attorney Docket Number   | H6810.0011/P011  |

11000 U.S. PTO 09/902170



| U.S. PATENT DOCUMENTS |                          |                      |                                      |  |  |  |
|-----------------------|--------------------------|----------------------|--------------------------------------|--|--|--|
| Examiner<br>Initials* | Cite<br>No. <sup>1</sup> | U.S. Patent Document |                                      | Name of Patentee or Applicant<br>of Cited Document | Date of Publication of<br>Cited Document<br>MM-DD-YYYY | Pages, Columns, Lines,<br>Where Relevant<br>Passages or Relevant<br>Figures Appear |
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| FOREIGN PATENT DOCUMENTS |                          |                         |                     |                                      |  |  |  |                |
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| OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS |                          |  |                |
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| Examiner<br>Initials*                             | Cite<br>No. <sup>1</sup> | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published. | T <sup>2</sup> |
| K.N.  | A                        | "Off Current Dependence on Farbrication Process of a Back-Channel-Etching-Type a-Si TFT" by Washizuka et al. (IDW 1997 pp. 207-210)  |                |
| K.N.  | B                        | Nikkei Microdevices (June, 2000 p.175)   |                |

|                       |                     |                    |          |
|-----------------------|---------------------|--------------------|----------|
| Examiner<br>Signature | <i>Khuemangayen</i> | Date<br>Considered | 10/31/02 |
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